



926.1008

UNITED STATES PATENT AND TRADEMARK OFFICE

Re: Application of: Guy CLAVAREAU et al.
Serial No.: 10/532,007
Filed: April 20, 2005
For: METHOD FOR MAGNETRON SPUTTERING

INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

May 20, 2005

Dear Sir:

Pursuant to M.P.E.P. §609 and 37 C.F.R. §§1.56, 1.97-1.99, applicant submits herewith an information disclosure citation which lists references of which the applicant is aware. A copy of each of the references is also submitted herewith.

An English translation of JP 3-271366 is not available at this time. However, an English-language abstract of this reference is submitted herewith. It is respectfully submitted that the relevance of this reference can be readily understood by referring to the drawings of the patent and corresponding English-language abstract provided.

I hereby certify that this correspondence and/or fee is being deposited with the United States Postal Service as "first class mail" in an envelope addressed to:
"Commissioner for Patents, P. O. Box 1450
Alexandria, VA 22313-1450"
on May 20, 2005.

STEINBERG & RASKIN, P.C.

BY: Janette M. Pherson

This submission does not represent that a search has been made or that no better art exists.

While the term "references" is used in citing the publications called to the examiner's attention herein, applicants do not make any admission that each or all of them are "prior art" references within the meaning of the statutory and case law.

Applicant reserves the right to contend, where appropriate, that a reference asserted against any claim of the present application is not prior art under the facts and the law.

Applicant also reserves the right to present appropriate arguments and/or evidence to establish patentability over the references, should one or more of the references be applied against the claims of the present application.

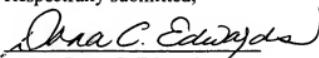
Applicant respectfully requests that the examiner independently determine those items which the examiner would consider the most pertinent of all the references cited herein.

Applicant respectfully requests that the references be considered and made of record.

This Information Disclosure Statement is being filed prior to the receipt of the first office action and therefore no fee is due. However, in the event that a fee is required, the Director is hereby authorized to charge any deficiency or credit any overpayment to Deposit Account No. 500518.

Respectfully submitted,

By:



Dona C. Edwards

Reg. No. 42,507

Enclos. PTO-1449
6 References
2 European Search Reports

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FORM PTO-1449 (REV. 7-80)		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		ATTY. DOCKET NO.: 926.1008		SERIAL NO.: 10532.007						
LIST OF PRIOR ART CITED BY APPLICANT (use several sheets if necessary)				APPLICANT(S): Guy CLAVAREAU et al.								
				FILING DATE: April 20, 2005		GROUP: Not yet known						
U.S. PATENT DOCUMENTS												
EXAMINER	INITIAL	DOCUMENT NUMBER				DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE		
	AA	5	4	1	5	7	5	4	05/1995	Manley	204	192.12
	AB	5	2	8	6	3	6	1	02/1994	Makowiecki et al.	204	298.12
	AC	4	8	9	2	6	3	3	01/1990	Welti	204	192.12
	AD											
	AE											
	AF											
	AG											
	AH											
	AI											
	AJ											
	AK											
FOREIGN PATENT DOCUMENTS												
		DOCUMENT NUMBER				DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION		
		AL	0	3	9	3	9	5	7		EPO	X
		AM	0	3	2	7	1	3	66		Japan	Abstract
		AN	1	0	6	3	6	7	9		EPO	X
		AO										
		AP										
OTHER PRIOR ART (Including Author, Title, Date, Pertinent Pages, Etc.)												
	AQ											
	AR											
	AS											
EXAMINER		/Jason Berman/				DATE CONSIDERED		05/27/2008				

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.